



EL 844050489

RECEIVED

#24/E  
T.BELL  
9.27.01

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

SEP 20 2001

Application Serial No. .... 09/059,644  
Filing Date ..... I.C. 2A00113, R008  
Inventor ..... Pai-Hung Pan  
Assignee ..... Micron Technology, Inc.  
Group Art Unit ..... 2822  
Examiner ..... M. Trinh  
Attorney's Docket No. .... MI22-898  
Title: Semiconductor Processing Methods of Forming a Conductive Gate  
and Line

**RESPONSE TO JUNE 20, 2001 OFFICE ACTION**

To: Box Non-Fee Amendment  
Assistant Commissioner for Patents  
Washington, D.C. 20231

From: Bernard Berman (Tel. 509-624-4276; Fax 509-838-3424)  
Wells, St. John, Roberts, Gregory & Matkin P.S.  
601 W. First Avenue, Suite 1300  
Spokane, WA 99201-3828

Sir:

Responsive to the Office Action dated June 20, 2001, Applicant respectfully requests reconsideration of the above-referenced application in view of the amendments and remarks that follow.